

## INFORMATION DISCLOSURE STATEMENT

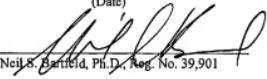
Applicant : Hada et al.  
App. No : 10/557,694  
Filed : November 22, 2005  
For : RESIN FOR PHOTORESIST  
COMPOSITION, PHOTORESIST  
COMPOSITION AND METHOD FOR  
FORMING RESIST PATTERN  
Examiner : Anca Eoff  
Art Unit : 1795

CERTIFICATE OF EFS WEB  
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(Date)

  
Neil S. Barfield, Ph.D., Reg. No. 39,901

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 2  
(two) references to be considered by the Examiner.

This Information Disclosure Statement is being filed after the mailing date of a final action or  
after the mailing date of a Notice of Allowance. This Statement is accompanied by the fee set forth in  
37 C.F.R. § 1.17(p). The Commissioner is hereby authorized to charge any additional fees which may  
be required or to credit any overpayment to Account No. 11-1410.

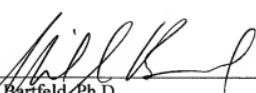
CERTIFICATION UNDER 37 C.F.R. § 1.97(e)(2)

I hereby certify that no item of information contained in this Statement was cited in a  
communication from a foreign Patent Office in a counterpart foreign application, and, to my  
knowledge after making reasonable inquiry, was known to any individual designated in 37 C.F.R.  
§ 1.56(c) more than 3 months prior to the filing of this Information Disclosure Statement.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 12/4/08

By: 

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